

Journal of  
**Photochemistry**  
and  
**Photobiology**  
**A: Chemistry**

Volume 163 (1–2) (2004)

---

**Editor-in-Chief**

R. P. Wayne  
(Oxford, UK)

**Associate Editors**

J. D. Coyle  
(Oxford, UK)  
N.S. Allen  
(Manchester, UK)

**North American Editor**

R. Schmechl  
(New Orleans, LA, USA)

**Asian Editor**

H. Masuhara  
(Osaka, Japan)

**Editorial Board**

A. U. Acuña (Madrid, Spain)  
R. A. Caldwell (Richardson, TX, USA)  
F. Catalina (Madrid, Spain)  
J. Delaire (Cachan Cedex, France)  
D. F. Eaton (Wilmington, DE, USA)  
S. J. Formosinho (Coimbra, Portugal)  
H. Fukumura (Sendai, Japan)  
K. Ghiggino (Melbourne, Australia)  
C. E. Hoyle (Hattiesburg, MS, USA)  
D. Husain (Cambridge, UK)  
H. Inoue (Tokyo, Japan)  
M. Irie (Fukuoka, Japan)  
E. Lissi (Santiago, Chile)  
B. Marciniak (Poznań, Poland)  
U. Mazzucato (Perugia, Italy)  
T. J. Meyer (Los Alamos, NM, USA)  
A. Mills (Glasgow, UK)  
D. C. Neckers (Bowling Green, OH, USA)  
B. Ohtani (Sapporo, Japan)  
D. Phillips (London, UK)  
J. C. Polanyi (Toronto, Ont., Canada)  
G. Poulet (Orleans cedex 2, France)  
I. Saito (Kyoto, Japan)  
J. C. Scaiano (Ottawa, Ont., Canada)  
R.P. Steer (Saskatoon, Sask., Canada)  
N. J. Turro (New York, NY, USA)



ELSEVIER

Amsterdam • Boston • Jena • London • New York • Oxford •  
Paris • Philadelphia • San Diego • St. Louis